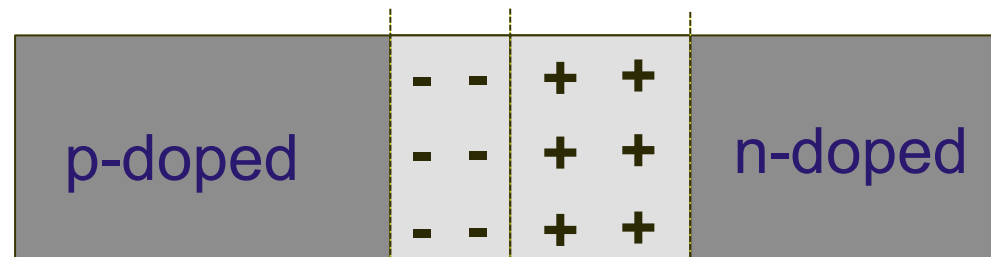


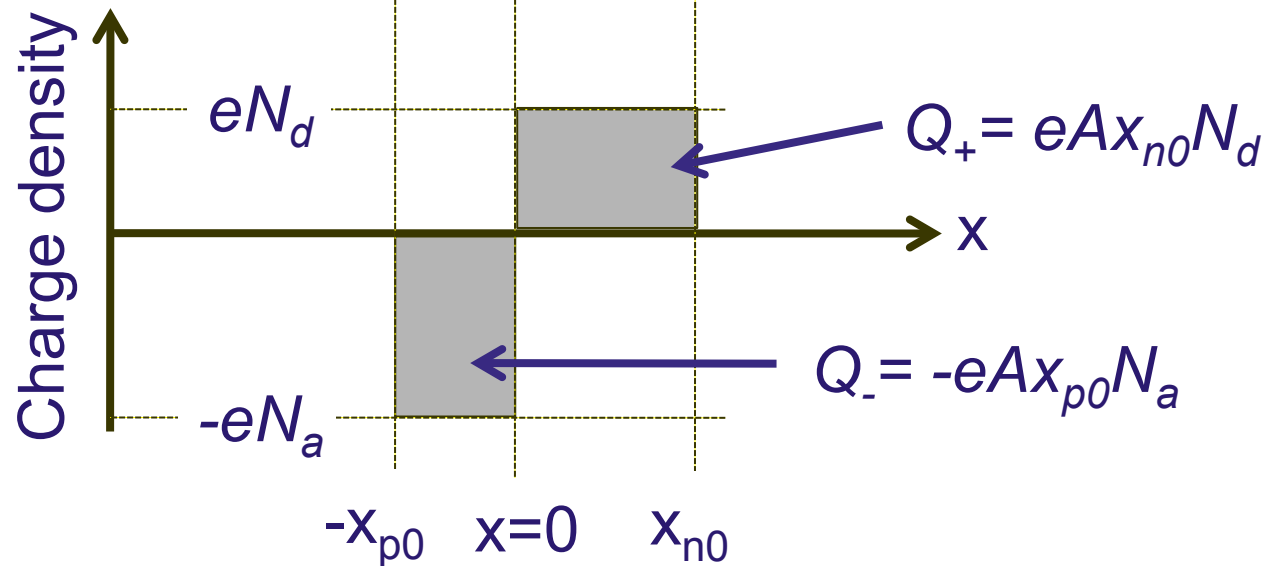
Lecture 11

- Poisson's Equation
- Space charge at the Junction
 - Depletion width
- Disturbing the equilibrium - qualitative
 - p-n junction under zero, forward, reverse bias

Space Charge at a Junction



Cross-sectional area A ,
doping densities of N_d , N_a for
donors and acceptors,
respectively.



Space Charge at a Junction

- Assume neutrality outside depletion region, W
- Neglect carriers within the depletion region
- Charge density in depletion region is governed by ionized dopants (assume all ionized at room temp)
- Total net charge in depletion region is zero to maintain overall charge neutrality

That is $eAx_{p0}N_a = eAx_{n0}N_d$ and $W = x_{p0} + x_{n0}$

Extent of depletion in each doped region depends on relative doping levels in that region (small doping large depletion and visa versa)

hence $x_{p0}N_a = x_{n0}N_d$ - we will use this a lot.....

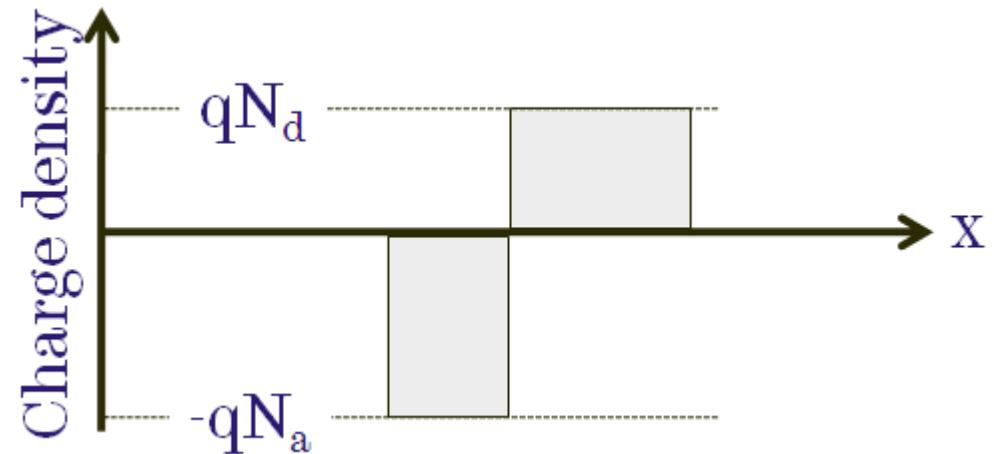
E-fields - Poisson's Equation

$$\frac{dE}{dx} = \frac{\rho}{\epsilon}$$

ρ is the space charge density

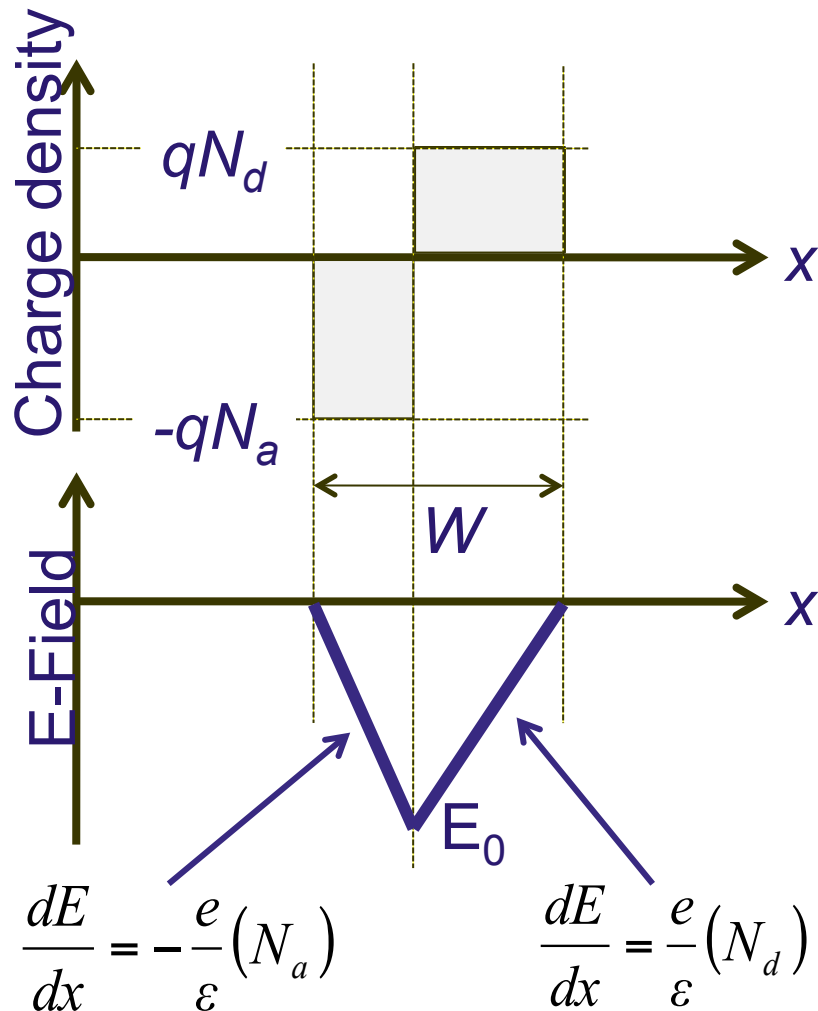
So generally

$$\frac{dE}{dx} = \frac{e}{\epsilon} (p - n + N_d - N_a)$$



- We can neglect n and N_d terms in this equation in the case of p-type regions and visa versa for n-type
- In neutral doped material $p = -N_a$ or $n = -N_d$ and $\frac{dE}{dx} = 0$

E-fields - Poisson's Equation



- **E**-field only present in 'space charge' region

- We know **E**-field is negative (in direction of -ve x)

- 2 regions, one +ve dE/dx and one -ve dE/dx

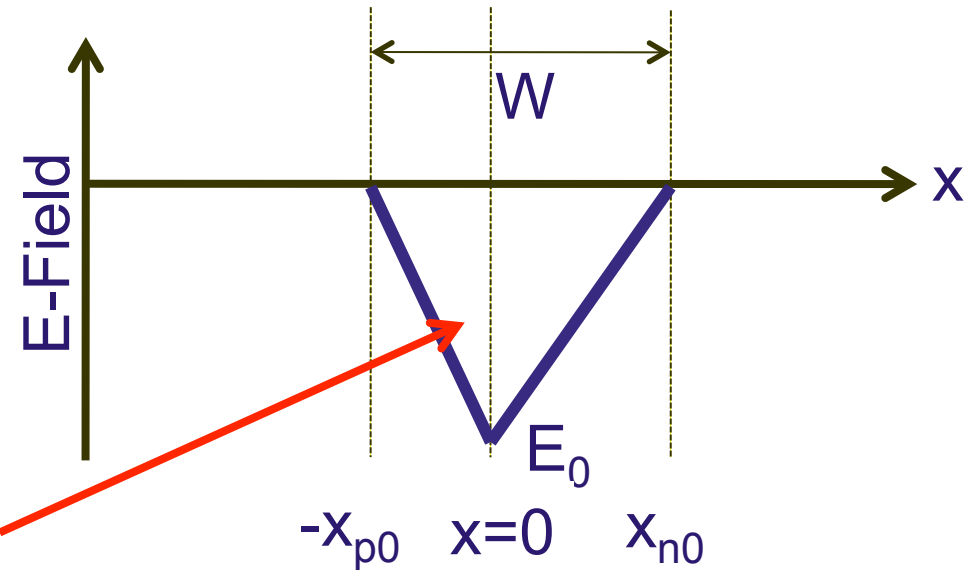
- Maximum **E**-field at physical junction between doped regions

Depletion Region – Built-in Voltage, V_0

$$E = -\frac{dV}{dx} \text{ or alternatively,}$$

$$-V_0 = \int_{-x_{p0}}^{x_{n0}} E(x) dx$$

So V_0 is area of this triangle

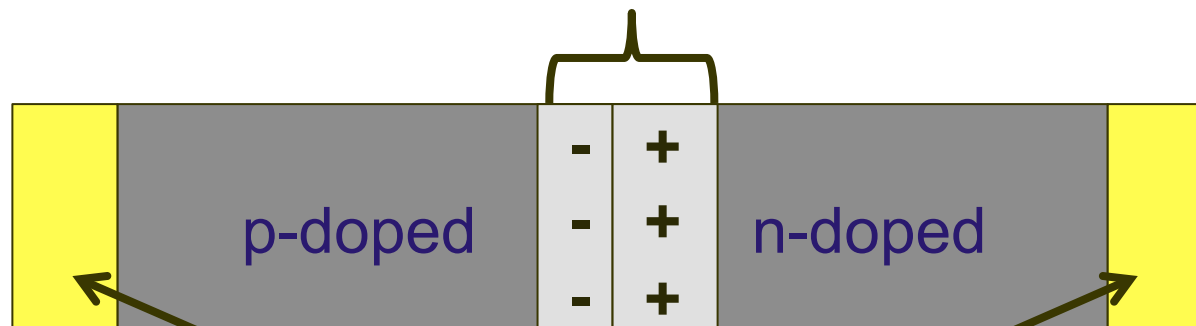


$$V_0 = -\frac{1}{2} E_0 W = \frac{1}{2} \frac{e}{\epsilon} N_d x_{n0} W = \frac{1}{2} \frac{e}{\epsilon} N_a x_{p0} W$$



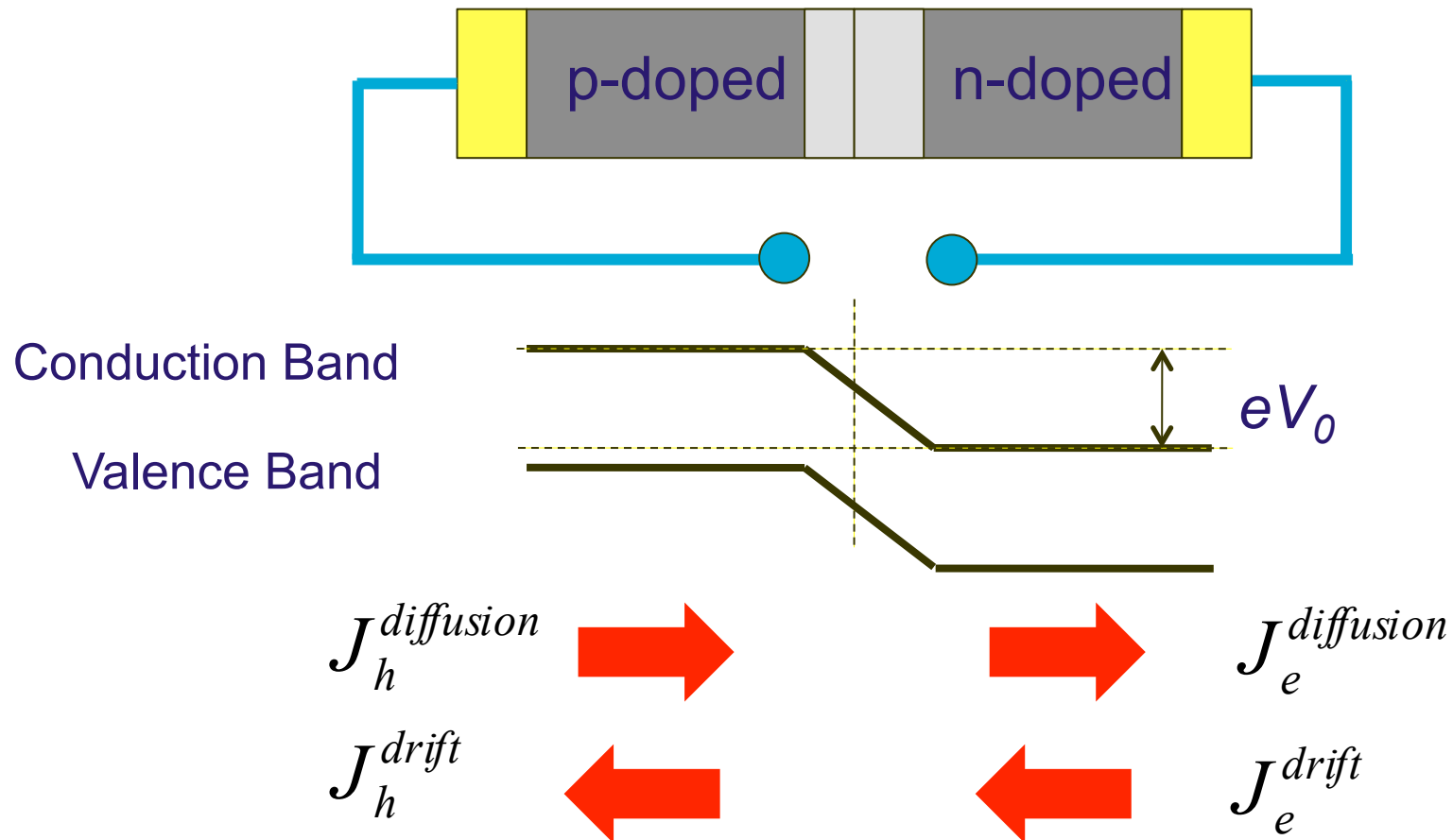
Complete Diode Structure

Depletion region – very low carrier density

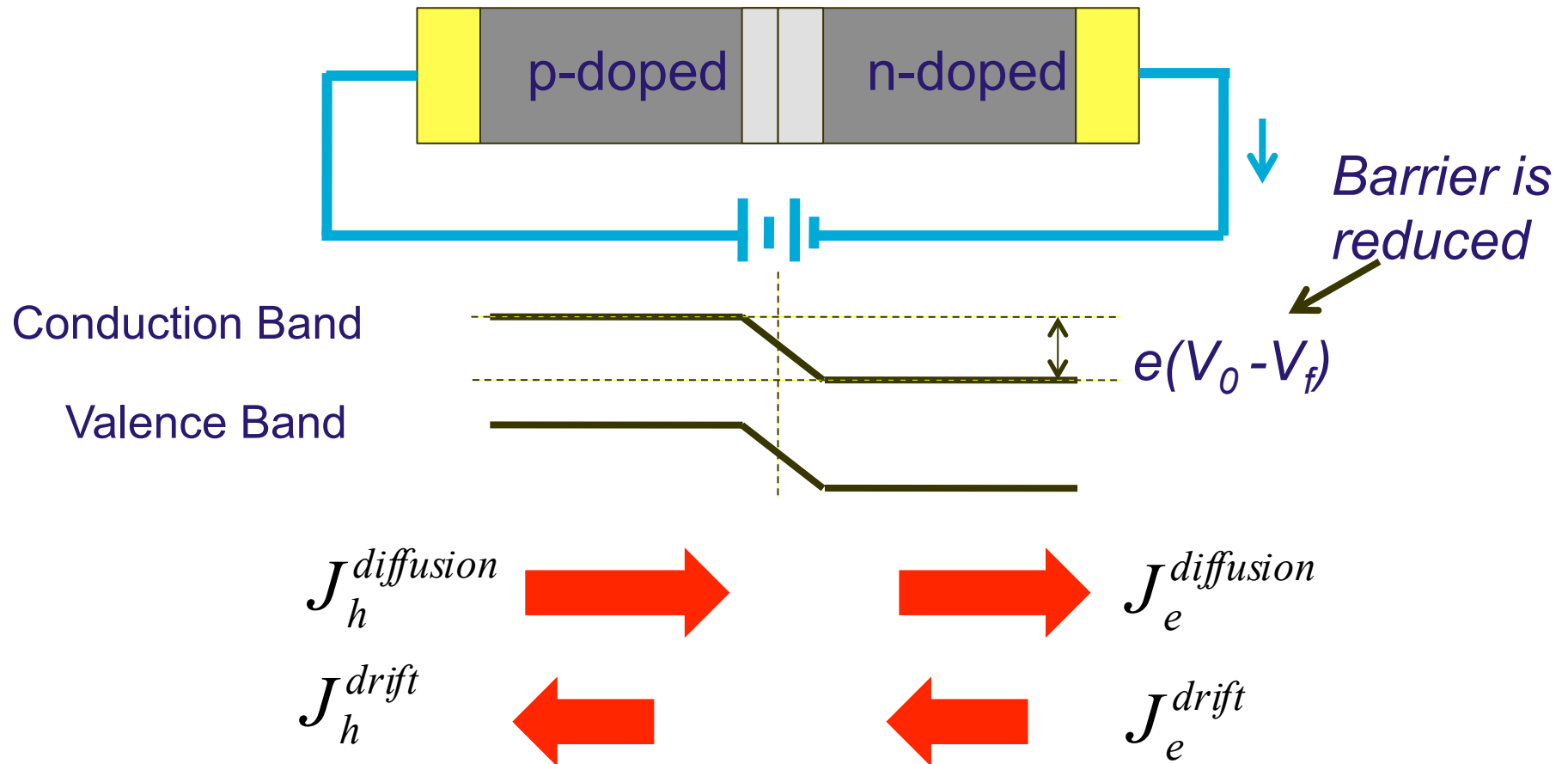


Metal contacts

Zero External Applied Voltage



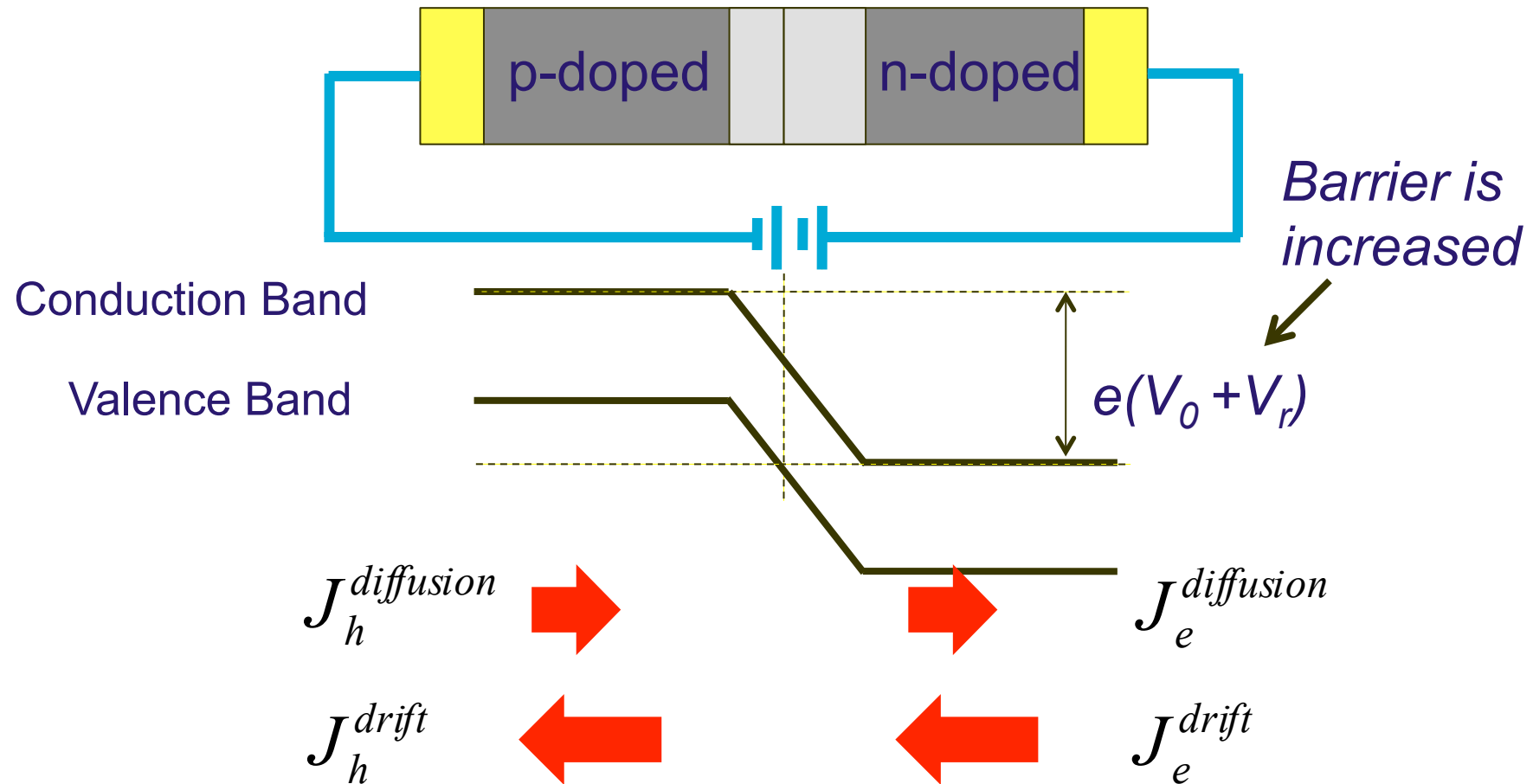
Forward Bias, V_f



Forward Bias, V_f - Current Imbalance

- Applied voltage changes the potential barrier and thus E -field within junction region - as we have forward bias the potential barrier is reduced
- The electric field in the transition region reduces
- This reduces the depletion region width (need fewer “exposed” ionized dopants to achieve this lower E -field)
- Diffusion Current is increased – potential barrier smaller – main current mechanism in diode
- Drift Current essentially same as zero bias - very few minority carriers to contribute to drift – so very small

Reverse Bias, V_r



Reverse Bias, V_r

- Applied voltage changes the potential barrier and thus E -field within junction region
- As we have reverse bias - the potential and the electric field is increased
- This increases the transition region width (need more “exposed” ionized dopants to achieve this higher E -field)
- Diffusion Current – potential barrier bigger – so reduced diffusion current
- Drift Current – same as zero bias - very few minority carriers to contribute to drift – so very small

Summary

- Poisson's equation relates electrostatic potential to charges present
- Space charge at the p-n junction determines the depletion region width, penetration into the n and p-doped regions, Electric-field and built in potential